

# Increasing the dot density in quantum dot infrared photodetectors via antimony mediated dot formation

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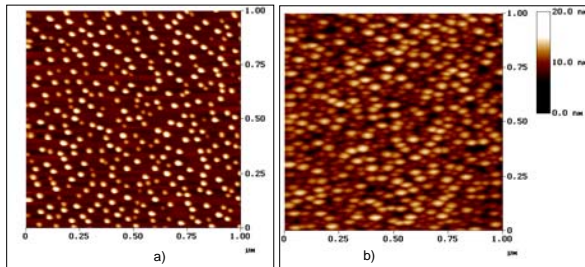
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## Motivation

- One of the key factors limiting the performance levels of QDIPs relative to quantum well infrared photodetectors (QWIPs) is the  $\sim 10\times$  lower intraband absorption strength for a single layer of QDs compared to a single QW.
- Main reason for the lower absorption: In-plane QD density limits the number of absorbing electrons to a few  $10^{10}\text{cm}^{-2}$  in a QDIP, compared with a few  $10^{11}\text{cm}^{-2}$  in a typical QWIP.
- We address this issue by depositing a thin layer of GaSb just prior to the InAs QD growth [1] as a method towards the realisation of the potential benefits of QDIPs, including longer excited lifetimes (higher responsivity) and normal incidence operation.

## Atomic force microscopy (AFM) of Sb-mediated grown structures

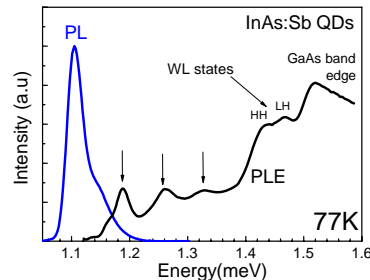


AFM images of :a) Standard In/GaAs dots, b) InAs on GaSb/GaAs dots

Increase in dot density from typically  $\sim 3\times 10^{10}\text{cm}^{-1}$  to  $\sim 6\times 10^{10}\text{cm}^{-1}$  for Sb pre-deposition before growth of wetting layer

## Photoluminescence

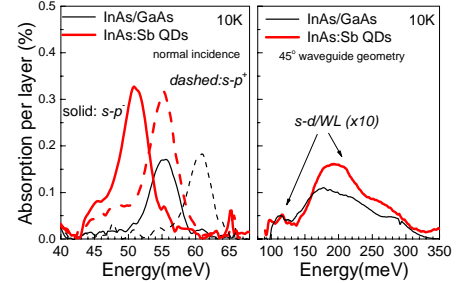
- QD energy configuration not altered with incorporation of antimony
- PL&PLE and intraband absorption studies can be used to estimate valence band energy levels



Photoluminescence and photoluminescence excitation for InAs in GaSb/GaAs dots

## Intraband Absorption

- Red-shift between InAs/GaAs and InAs on GaSb/GaAs dots within the range of 48-60meV- ( typical for standard QD structures, depending on growth parameters)
- Absorption per layer of  $\sim 15\%$  for  $s-d$  and  $s-WL$  transitions, and **35%** for normal incidence absorption from  $s-p$  state

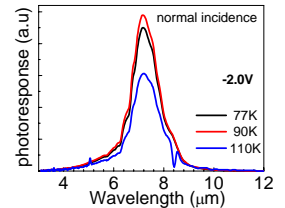


Absorption per layer for  $s-p$  and  $s-d$  and  $s-WL$  states for samples with and without antimony

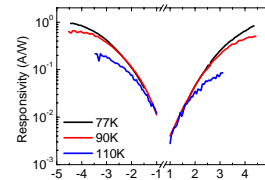
- Conduction band structure unaltered, unlike other approaches for producing high QD densities which lead to formation of coalesced QDs or quantum dashes [2]
- Low energy shoulder of  $s-p'$  peak attributed to effect of bimodal distribution for the Sb-sample

## DWELL QDIP with GaSb

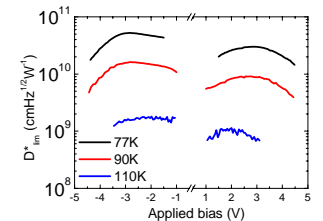
- Above technique applied for the fabrication of a quantum dots-in-a-well (DWELL) infrared photodetector
- narrow photoresponse at  $\sim 8\mu\text{m}$  up to temperatures of **110K**
- Responsivity of **1A/W** at 77K scaling down to only 0.12A/W at 110K



Spectral response of DWELL infrared detector with GaSb



Responsivity of DWELL detector with GaSb



Detectivity of  $5\times 10^{10}\text{cmHz}^{1/2}\text{W}^{-1}$  at 77K

**Incorporating Sb in DWELL QDIPs is a very promising technique for high performance detectors**

related work published in Applied Physics Letters, P. Aivaliotis et al, APL 91,013503 (2007)